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PATENT
29925/39915

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Min Ho Jung et al.

Serial No.: 10/789,055

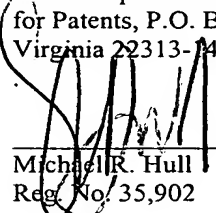
Filed: February 27, 2004

For: Additive for Photoresist
Composition for Resist Flow Process

Group Art Unit: 1752

Examiner: To be assigned

) I hereby certify that this paper and the
) documents referred to as enclosed
) therewith are being deposited with the
) United States Postal Service as First Class
) Mail, postage prepaid, on **June 1, 2004**, in
) an envelope addressed to Commissioner
) for Patents, P.O. Box 1450, Alexandria,
) Virginia 22313-1450

) 
) Michael R. Hull
) Reg. No. 35,902

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

Submitted herewith for consideration by the Examiner are documents identified on the attached Form PTO-1449. Entry and consideration of the identified documents are solicited.

This Information Disclosure Statement is being submitted before receipt of a first Office Action on the merits and, consequently, should be considered by the Patent Office without payment of a fee. See 37 C.F.R. § 1.97(b)(3).

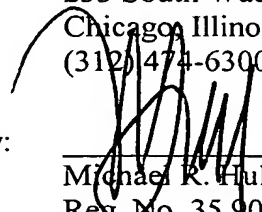
However, if any additional fee is required for the consideration of this information, the Commissioner for hereby authorized to charge such fee to Deposit Account No. 13-2855.

Respectfully submitted,

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June 1, 2004

By:


Michael R. Hull
Reg. No. 35,902



Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Atty. Docket No. 30205/37328A	Serial No. 10/789,055
INFORMATION DISCLOSURE STATEMENT		Applicants Min Ho Jung et al.	
		Filing Date February 27, 2004	Group 1752

U.S. PATENT DOCUMENTS							
*Examiner Initials		Document Number	Issue Date	Name	Class	Subclass	Filing Date if Appropriate
		5,276,126	01/04/1994	Rogler			
		5,580,694	12/03/1996	Allen et al.			
		5,786,131	07/28/1998	Allen et al.			
		5,998,099	12/07/1999	Houlihan et al.			
		6,180,316 B1	01/30/2001	Kajita et al.			
		6,268,106 B1	07/31/2001	Park et al.			
		6,391,518 B1	05/21/2002	Jung et al.			
		6,497,987 B1	12/24/2002	Kim et al.			

FOREIGN PATENT DOCUMENTS								
*Examiner Initials		Document Number	Publication Date	Country	Class	Subclass	Translation	
							Yes	No

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)		

EXAMINER	DATE CONSIDERED
<p>*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance <u>and</u> not considered. Include copy of this form with next communication to applicant.</p>	